



Patent Application No. 10/692,030  
Customer Number: 42717

IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Syun-Ming Jang, et al.	§	Docket No.:	24061.468
		§		(TSMC2002-0130)
Serial No.:	10/692,030	§		
		§	Examiner:	Calvin Lee
Filing Date:	October 23, 2003	§		
		§	Art Unit:	2825
For:	SiOC Properties and Its Uniformity	§		
	in Bulk for Damascene	§	Conf. No.:	6421
	Applications	§		

**RESPONSE TO RESTRICTION REQUIREMENT**

Mail Stop: Amendment  
Commissioner for Patents  
PO Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed January 26, 2004, applicant hereby elects Group I, Claims 1-31, which is drawn to a method of forming a dielectric material layer.

Applicant's election is made with traverse on the grounds that the embodiments delineated by the examiner are not patentably distinct and therefore constitute a single invention concept.

An early action on the merits is respectfully requested.

Respectfully submitted,

*Timothy F. Bliss*

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Date: 10/8/04

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**CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Mail Stop: Amendment, Commissioner For Patents, PO Box 1450, Alexandria, VA 22313-1450 on the date below.

*Dayle Conner*  
Name

*10-8-04*  
Date